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(12) **United States Design Patent**
Carter

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(54) **APERTURED, CONTINUOUS FILAMENT FABRIC**

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(**) **Term:** **14 Years**

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(57) **CLAIM**

The ornamental design for an apertured, continuous filament fabric, as shown and described.

DESCRIPTION

The sole FIGURE is a fragmentary, elevational view of one face of an apertured, continuous filament fabric showing my new design.

1 Claim, 1 Drawing Sheet



